

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	Attorney Docket No.: SOEI0021
Ken SAWABE et al.)	Confirmation No. 9014
Serial No.: 10/595,920)	Group Art Unit: 1795
Filed: May 19, 2006)	Examiner: Amanda C. WALKER
For: PHOTSENSITIVE RESIN)	Date: April 10, 2009
COMPOSITION, PHOTSENSITIVE)	
ELEMENT, RESIST PATTERN)	
FORMING METHOD AND PROCESS)	
FOR MANUFACTURING PRINTED)	
CIRCUIT BOARD)	

AMENDMENT (E)

MAIL STOP: RCE

United States Patent and Trademark Office
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Alexandria, VA 22314

Sir:

In response to the FINAL Office Action mailed December 11, 2008, and in view of the Request for Continued Examination (RCE) filed herewith, please amend the application identified above as follows:

Amendments to the Claims are reflected in the listing of claims that begins on page 2 of this paper.

Remarks/Arguments begin on page 9 of this paper.